

10/018690

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PATENT NUMBER and  
ISSUE DATE

## U.S. UTILITY Patent Application

APPL NUM 10018690	FILING DATE 12/20/2001	CLASS 430	SUBCLASS 322	GAU 1756	EXAMINER <i>Chacko Davis</i>
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\*\*APPLICANTS: Chiba Tatsuo; Ichikawa Tatsuya;

## \*\*CONTINUING DATA VERIFIED:

THIS APPLICATION IS A 371 OF PCT/JP00/04028 06/21/2000

## \*\* FOREIGN APPLICATIONS VERIFIED:

JAPAN 11/177587 06/24/1999

JAPAN 2000/52990 02/29/2000

PG-PUB	<input type="checkbox"/> DO NOT PUBLISH	<input type="checkbox"/> RESCIND	
Foreign priority claimed 35 USC 119 conditions met	<input type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> yes <input type="checkbox"/> no	ATTORNEY DOCKET NO TSUK 0305	
Verified and Acknowledged Examiner's initials			
TITLE : Photosensitive element, photosensitive element roll, process for producing resist pattern with the same, resist pattern, substrate with overlying resist pattern, process for producing wiring p U.S. DEPT. OF COMM./PAT. & TM-PTO-535 (Rev. 12-94)			

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED	
			Total Claims	Print Claim for Q.G.
ISSUE FEE		DRAWING		
Amount Due	Date Paid	Sheets Drawg.	Figs. Drawg.	Print Fig.
TERMINAL		Primary Examiner		
DISCLAIMER		PREPARED FOR ISSUE		
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